Veeva Publishing eLearning

Accelerate user onboarding and stay current with new features and best practices

Vault Submissions Publishing eLearning is an online training program that educates users on the process for creating compliant publishing content from initial planning to final submission. It is an on-demand, self-paced, computer-based training with regular updates that mirror Veeva's product release cycle. Users always have access to the latest release-based training, best practice recommendations, and current information to stay compliant with health authority guidance.

Benefits

- · Onboard more quickly with on-demand product and best practices training.
- Remain current with new release training on latest features, UI changes, and recommendations.
- Leverage on-the-job training with microlearning courses covering specific use cases and complex features.
- Eliminate time and resources developing, delivering, and maintaining custom training programs.

Features

Initial onboarding for Vault Submissions Publishing

- Process-based training for new users.
- Key process steps from application creation to submission of compliant content.
- Current Veeva recommended best practices on Veeva's template.

Stay up-to-date with new release training

- · Presents an overview of features impacting end users.
- Highlights relevant Vault Submissions Publishing, Vault Submissions, Vault Submissions Archive, and Vault Platform features.
- · Reviews auto-on and key configurable features and impact.

On-the-job training with micro-learning

- Library of courses and micro-learnings for on-the-job training, including region-specific publishing considerations, advanced hyperlinking, and handling large file formats.
- Course library will grow as new capabilities become available and includes industry changes such as eCTD 4.0.

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